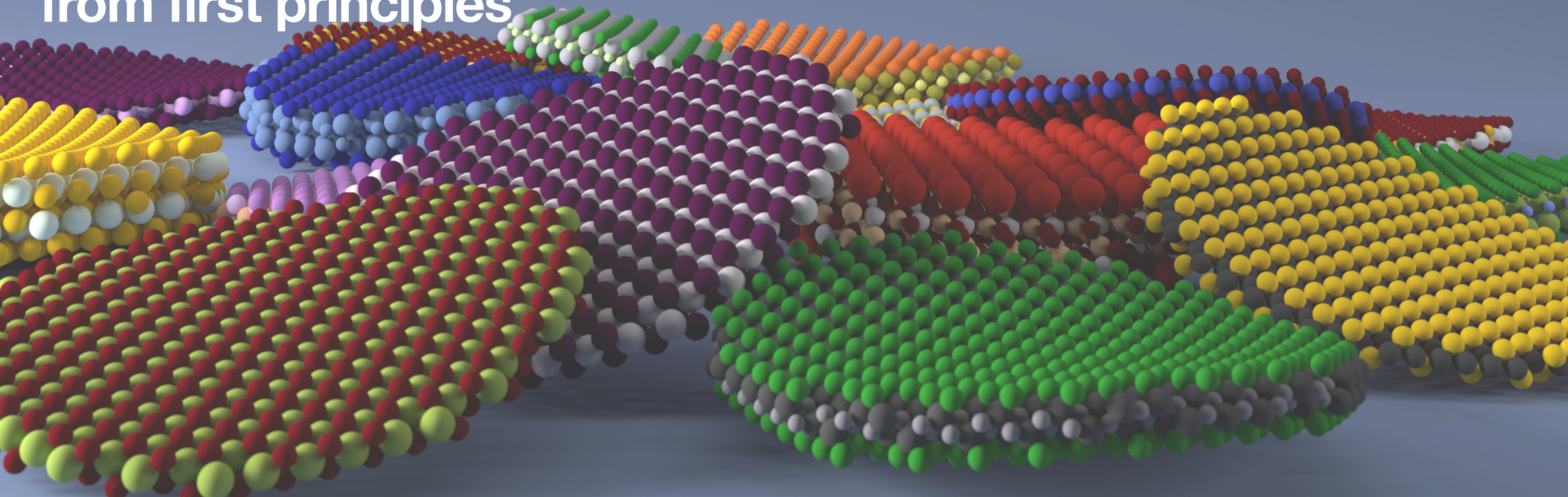




# Finding and engineering high-conductivity 2D semiconductors from first principles



Thibault Sohier

GDR IAMAT - Annual Meeting - June 1st 2022

# Discovery and Design

## High-mobility quest

~100,000

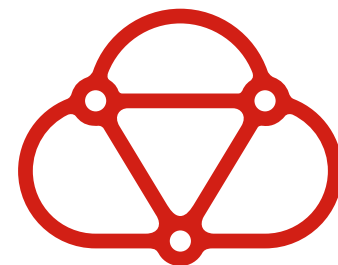
Experimentally known 3D compounds

~1000

Easily Exfoliable materials

~250

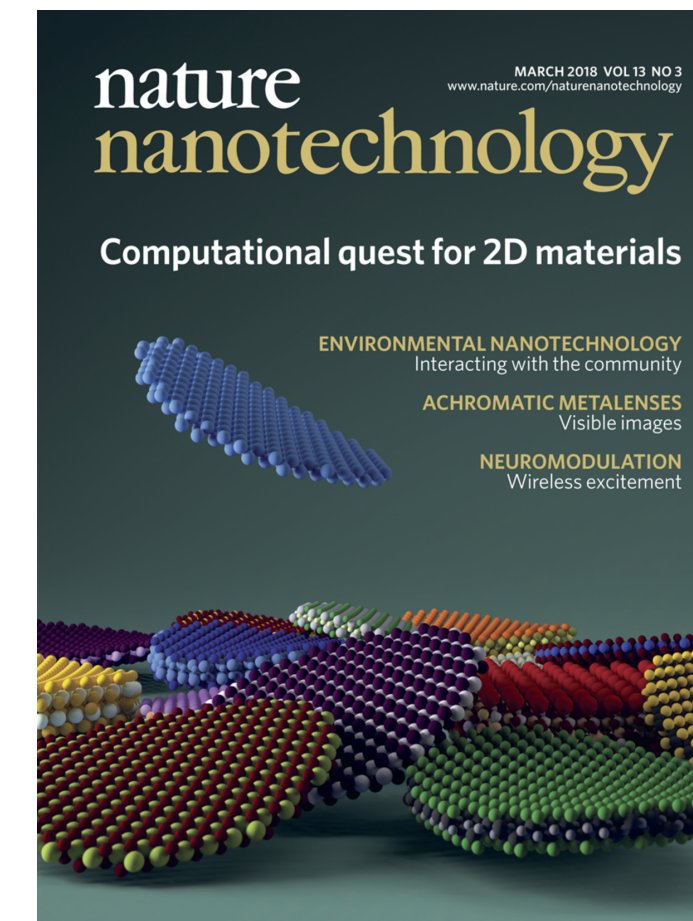
Small unit cells  
( $\leq 6$  atoms)



**MATERIALSCLOUD**

<https://www.materialscloud.org/>

From 2D team @ THEOS:



[Mounet et al. Nature Nanotechnology **13**, 246–252 (2018)]

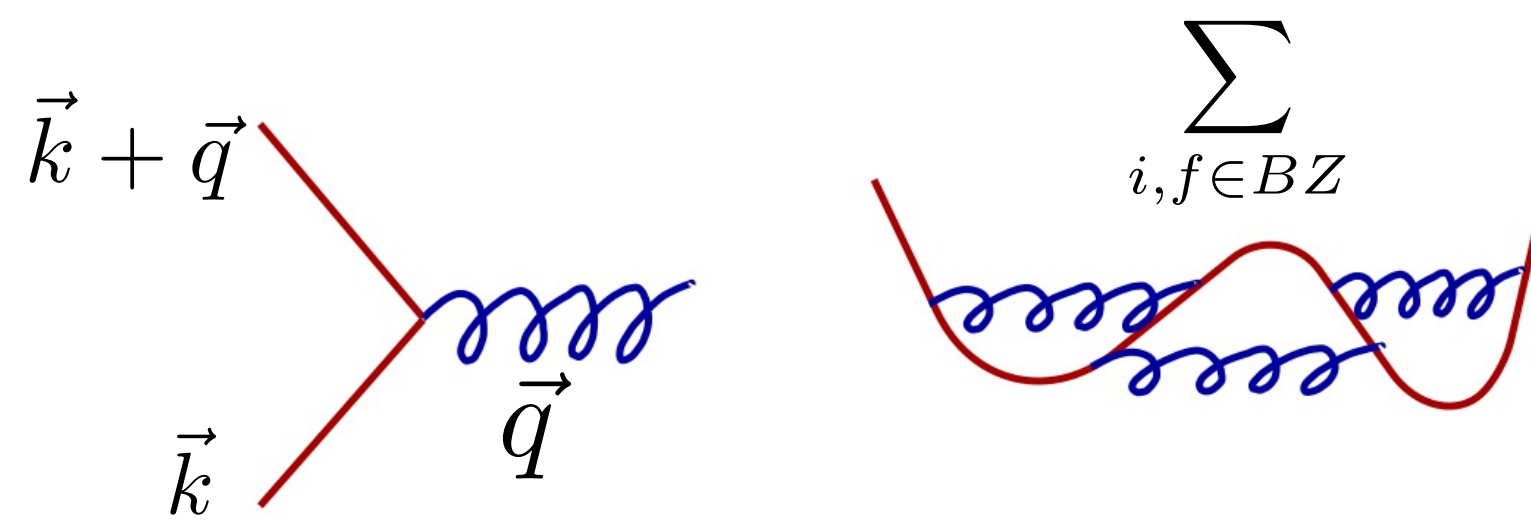
How to find high conductivity semiconductors?

# High-mobility 2D materials

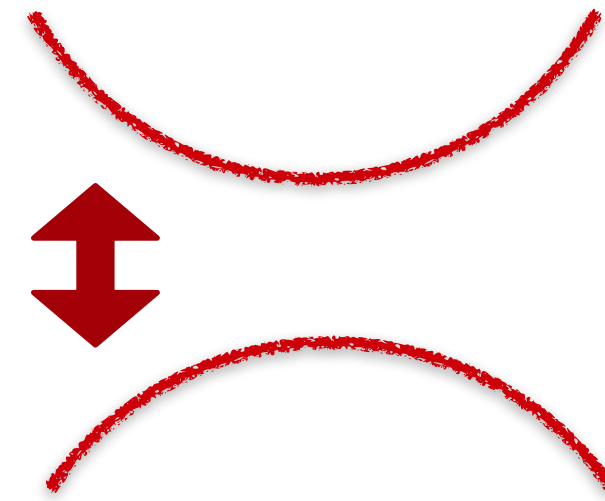
## Context

Phonon-limited charge transport in gated 2D semiconductors

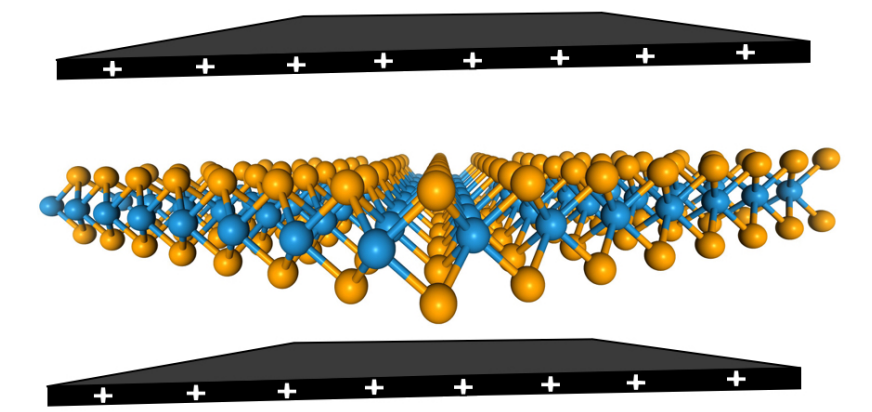
- Only electron-phonon scattering



- Materials with a gap



- Electrostatic doping



Objective:

High conductivity / mobility

Why?

- Applications: transistors, sensors, optoelectronics...
- Physics of electron-phonon scattering

How?

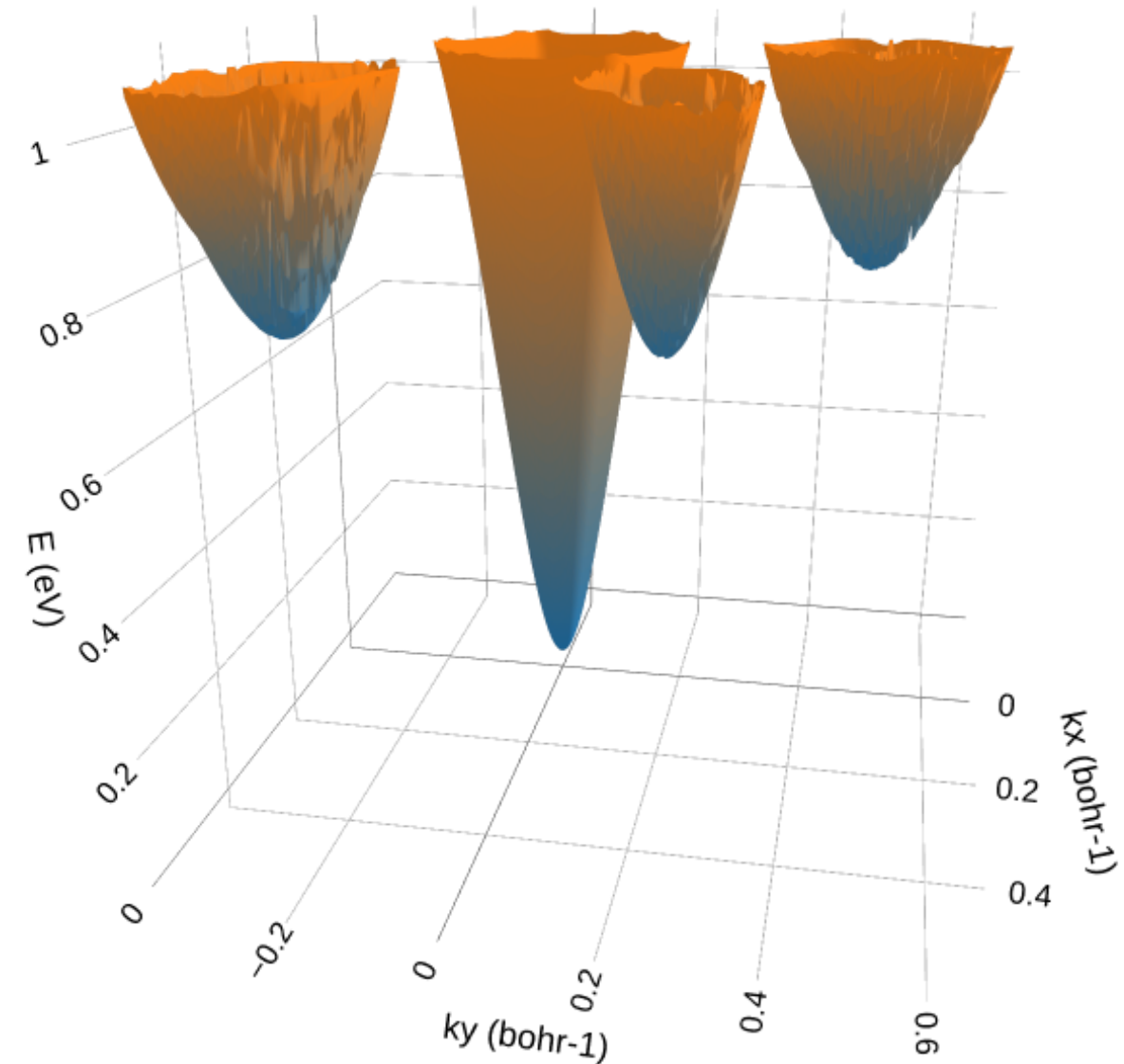
- Intrinsic (discovery) and/or engineered (design)

# Profiling high-conductivity materials

## Learn from the bests

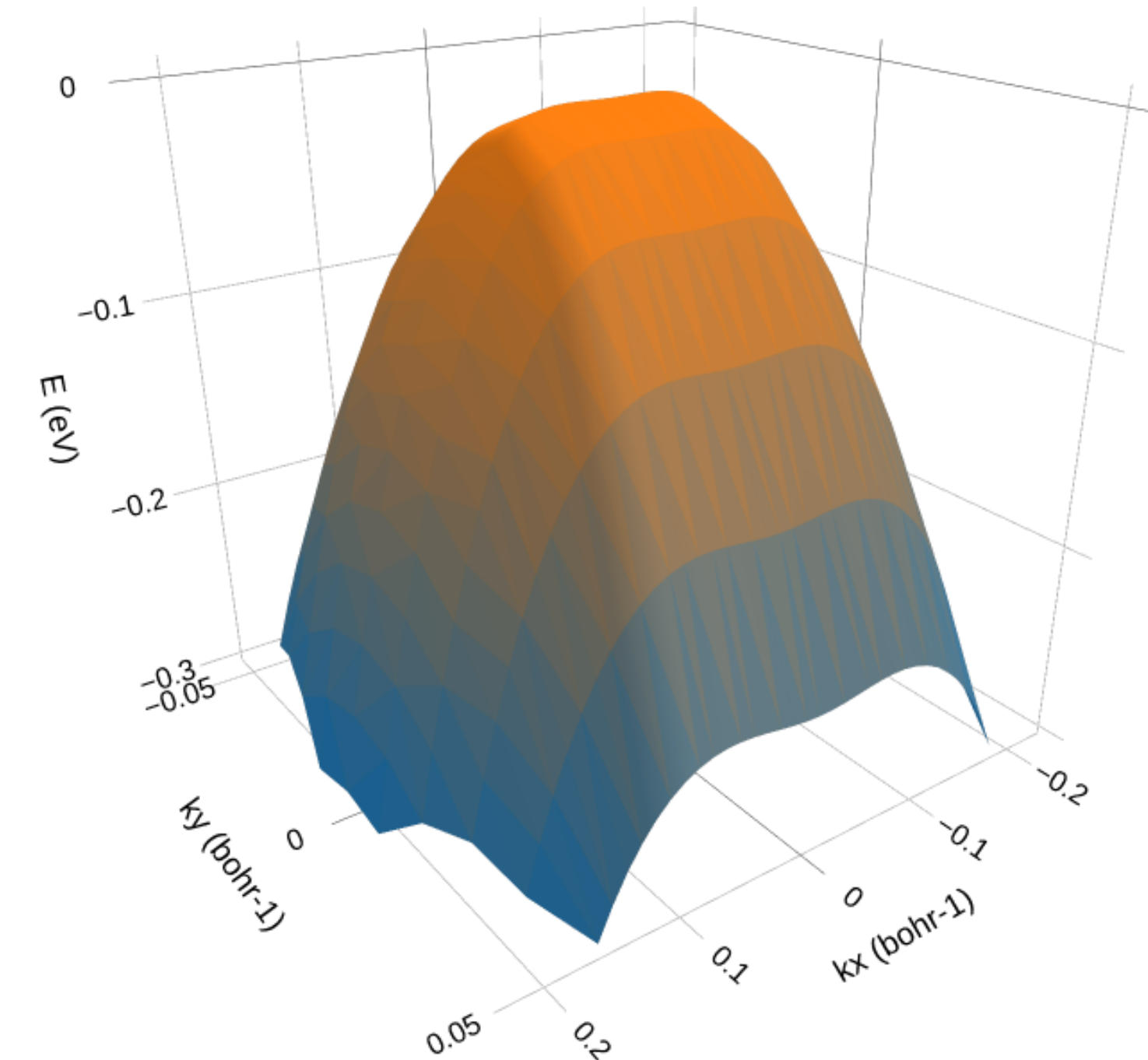
(Electronic) structure-property relation

InSe (electrons)



Steep and deep single valley

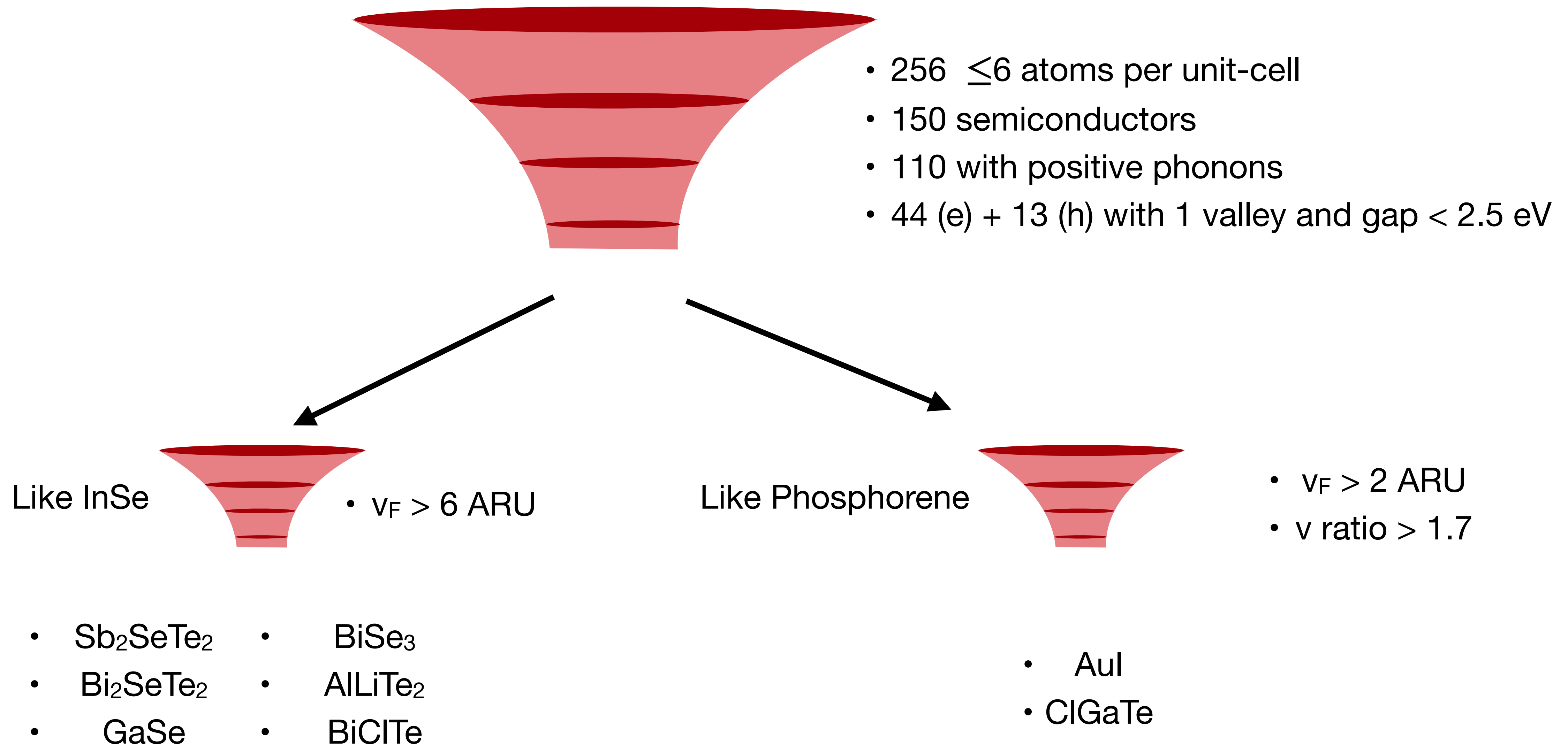
P4 (holes)



Anisotropic single valley

# Profiling high-conductivity materials

## Screening procedure

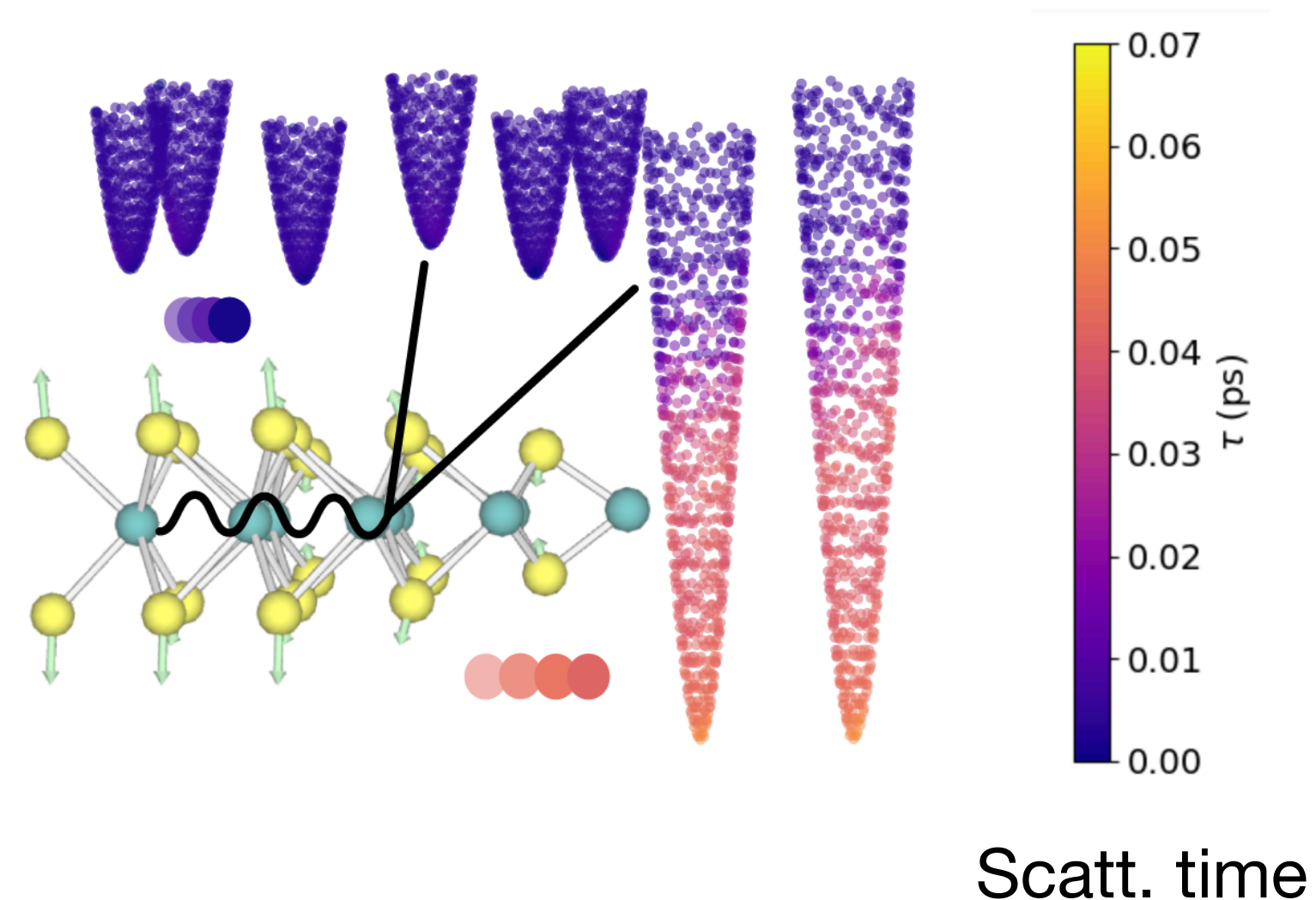


# Profiling high-conductivity materials

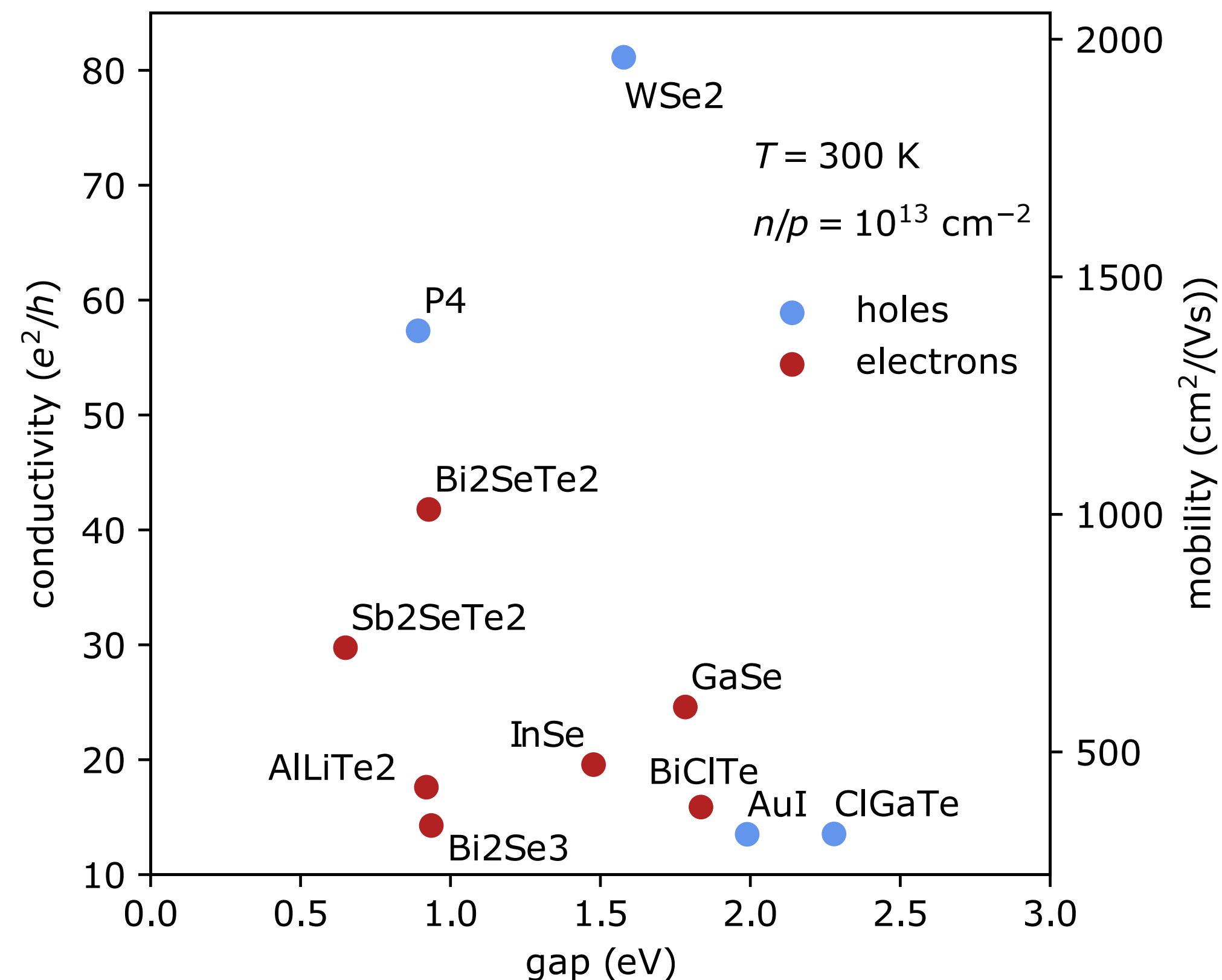
## A dozen excellent candidates



Predictive and automated transport workflow



$$\sigma = 2e^2 \int_{\mathbf{k}} \frac{d\mathbf{k}}{(2\pi)^2} (\mathbf{v}(\mathbf{k}) \cdot \mathbf{u}_{\mathbf{E}})^2 \tau(\mathbf{k}) \frac{\partial f^0}{\partial \varepsilon}$$



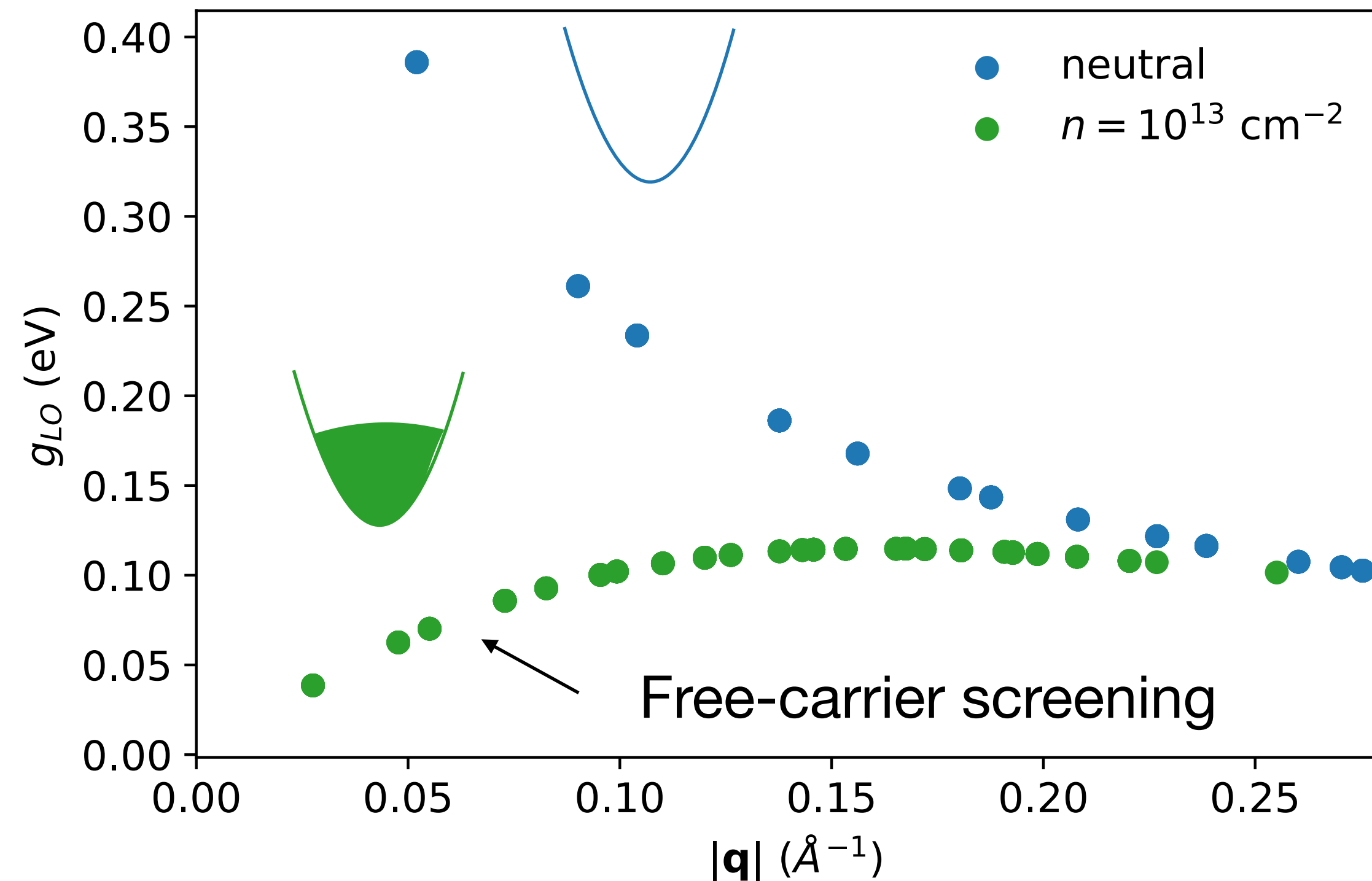
Full provenance available on Materials Cloud archive

Most electron-doped monolayers are limited by Fröhlich interactions...

# Remote screening

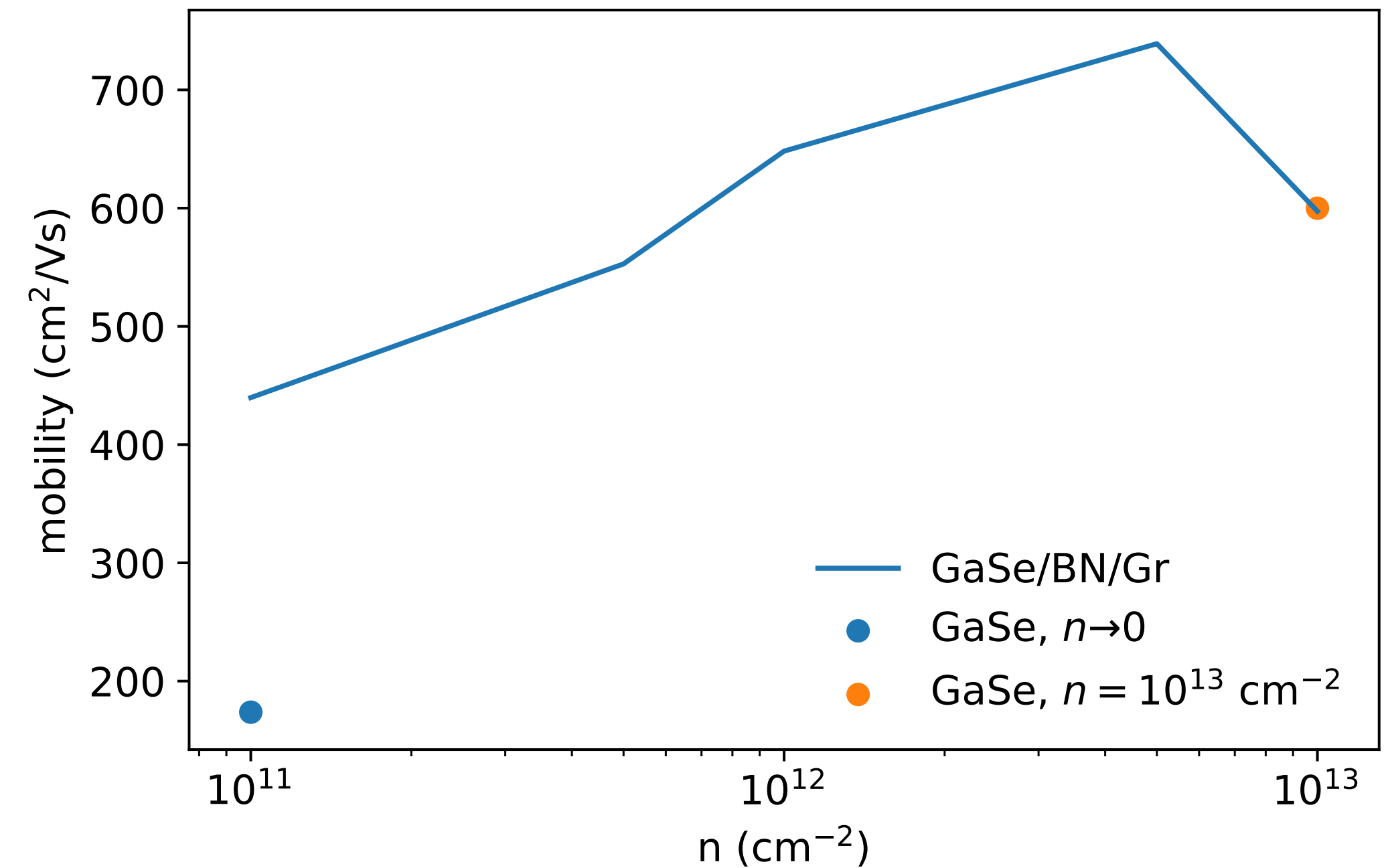
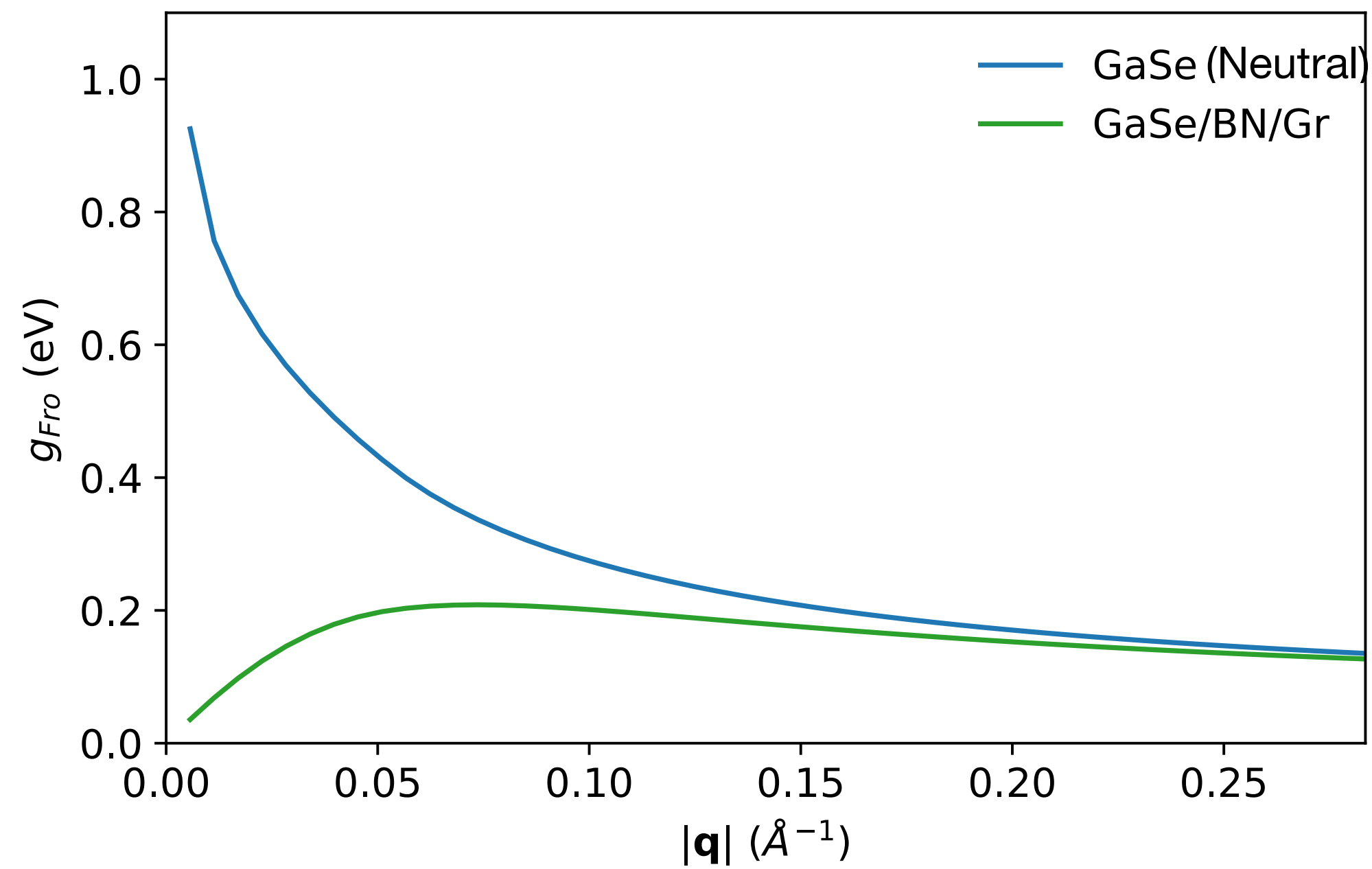
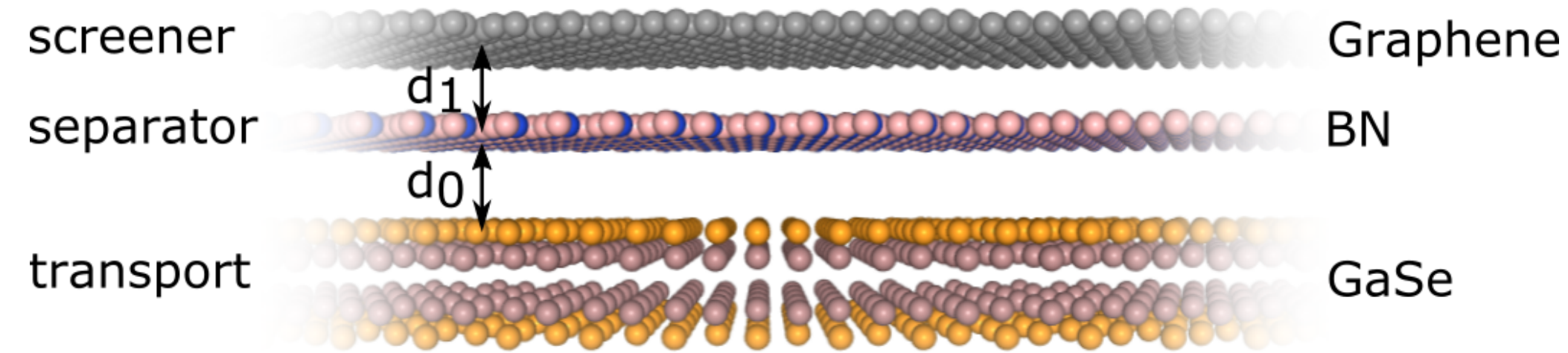
## GaSe, a prototypical Fröhlich-limited material

$n$ (cm <sup>-2</sup> )	10 <sup>13</sup>	10 <sup>11</sup> (~ neutral)
$\mu$ (cm <sup>2</sup> /(Vs))	600	174



# Remote screening

## Mobility enhancement at low carrier density

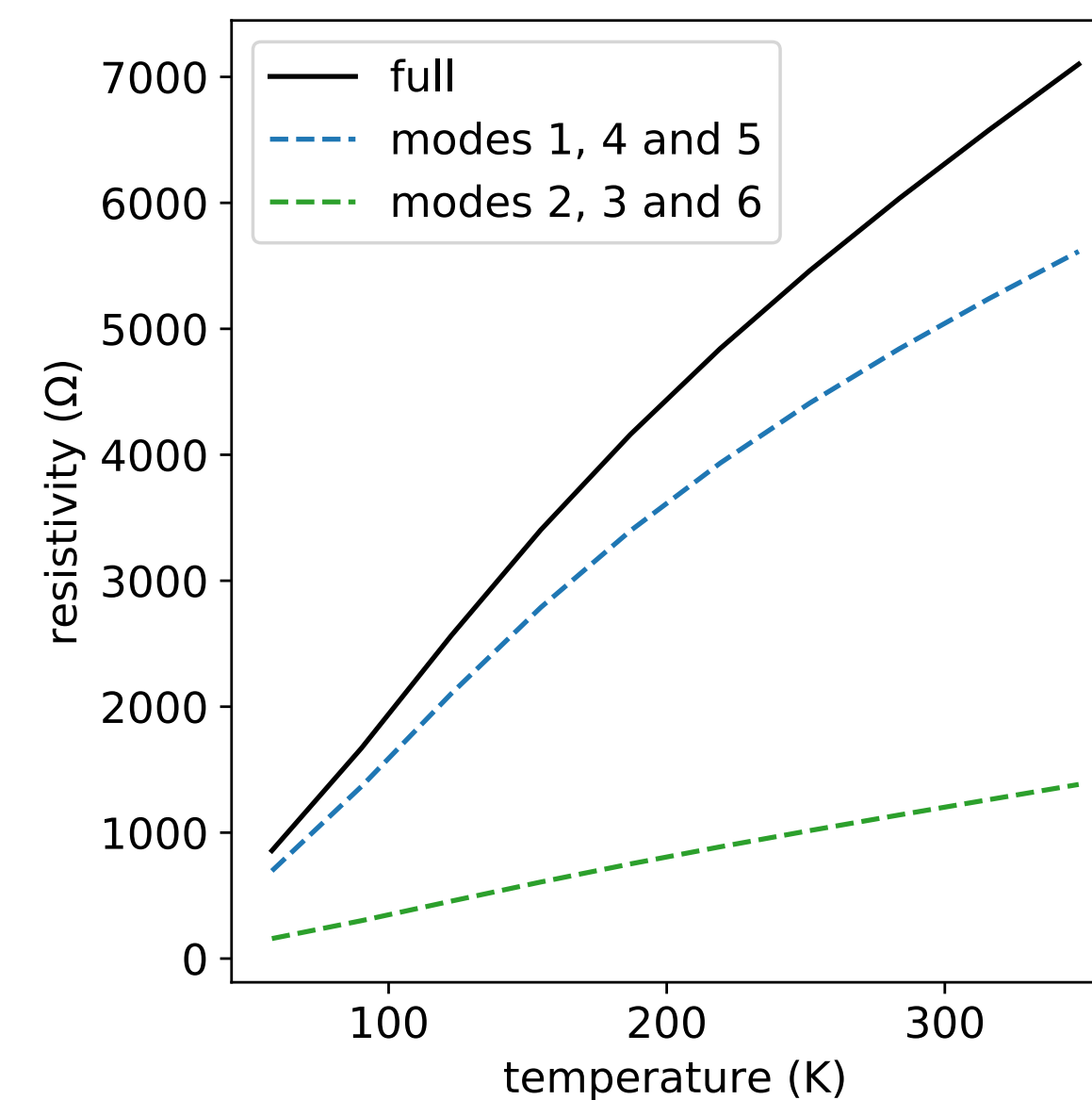
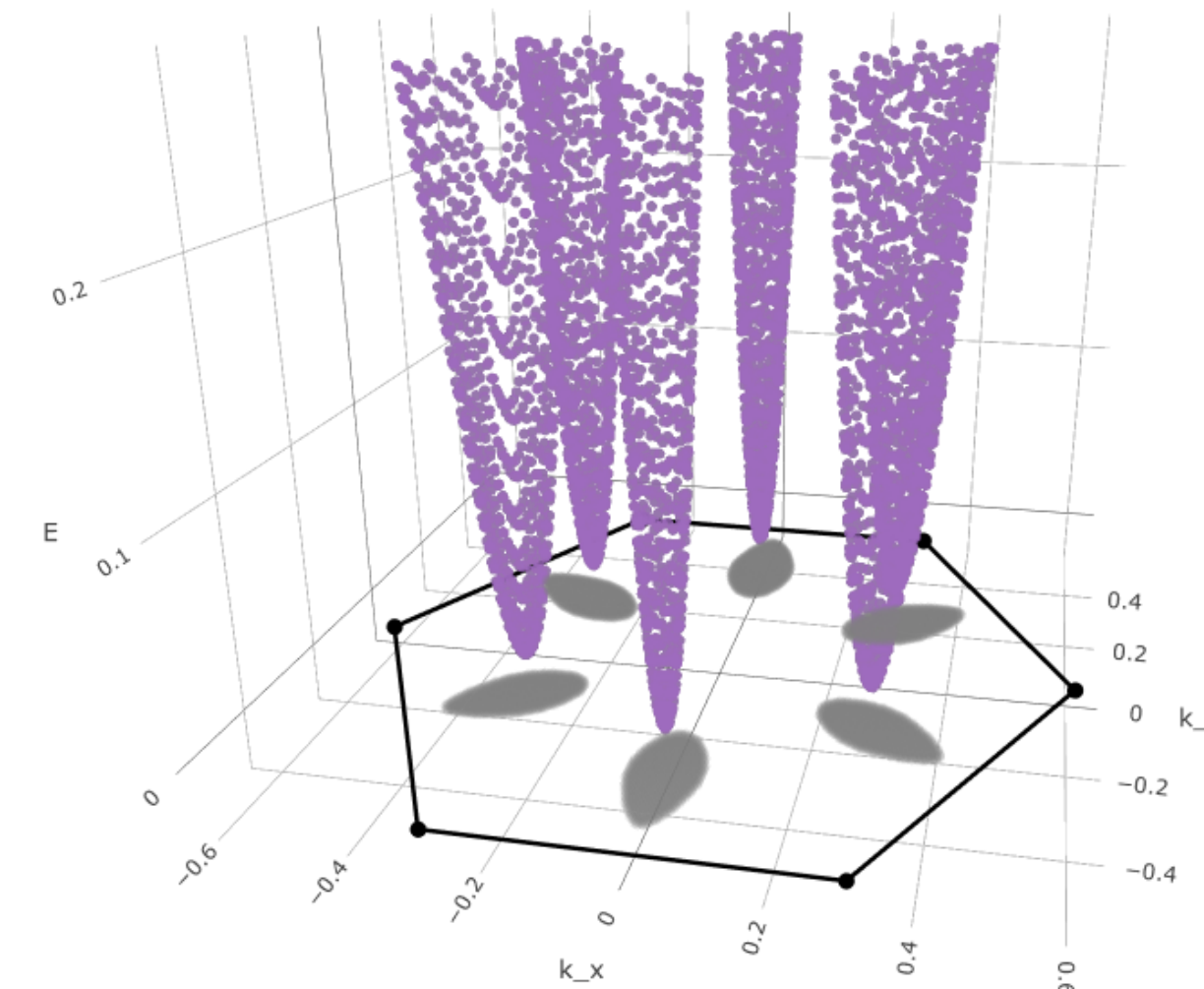
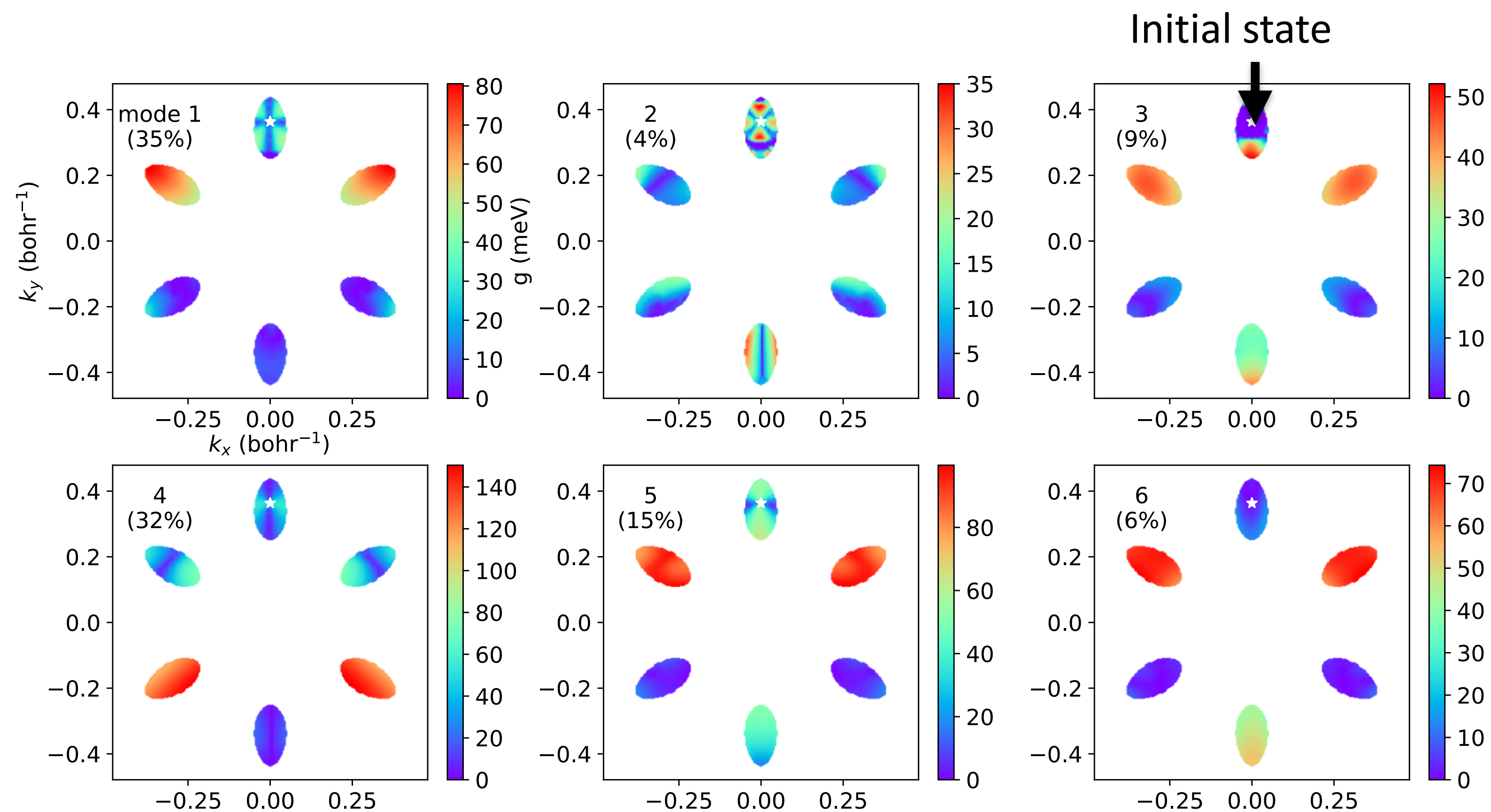


Works for any material dominated by screenable el-ph coupling



# Valley-engineering

## Arsenene: the role of intervalley scattering

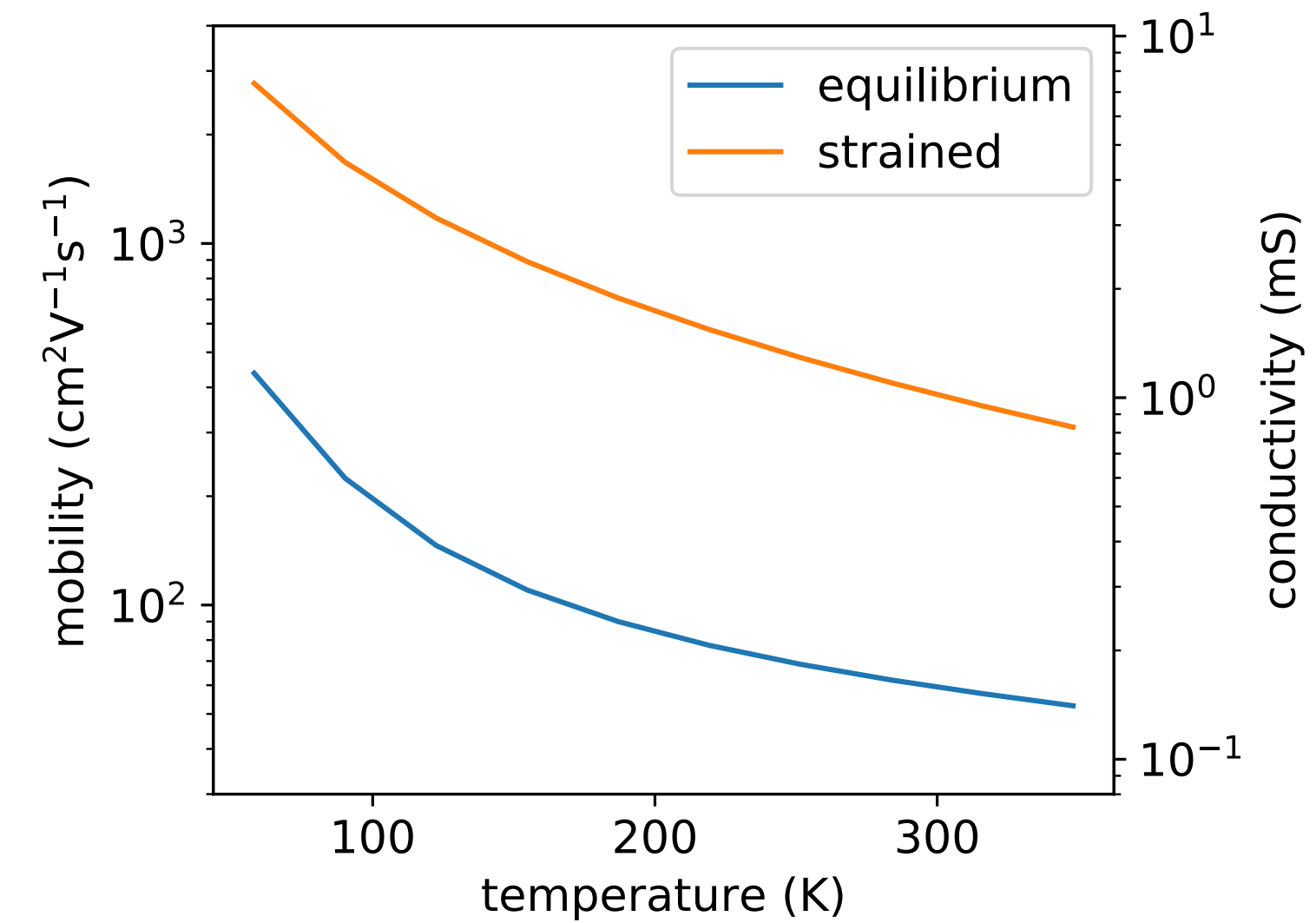
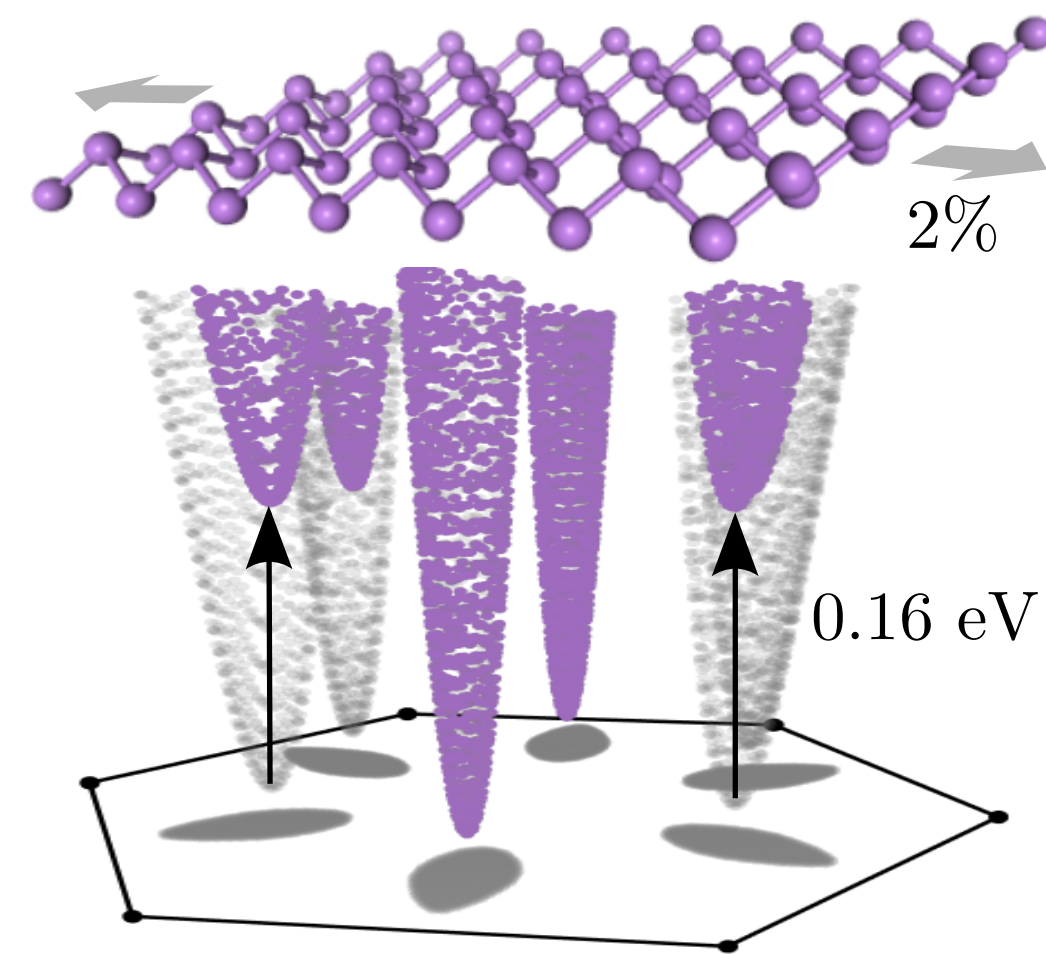


Transport dominated by intervalley scattering

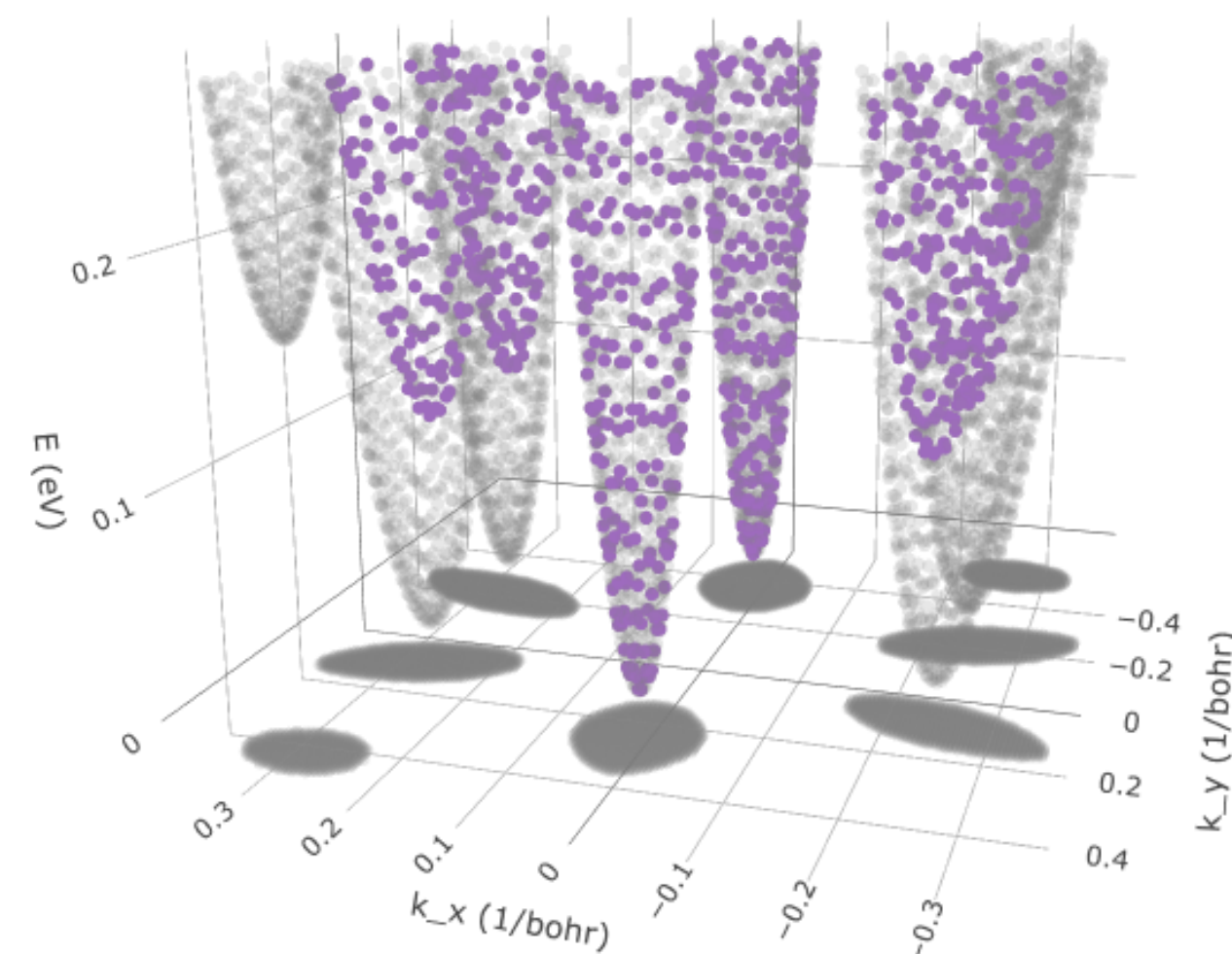
# Valley-engineering

## Mobility enhancement

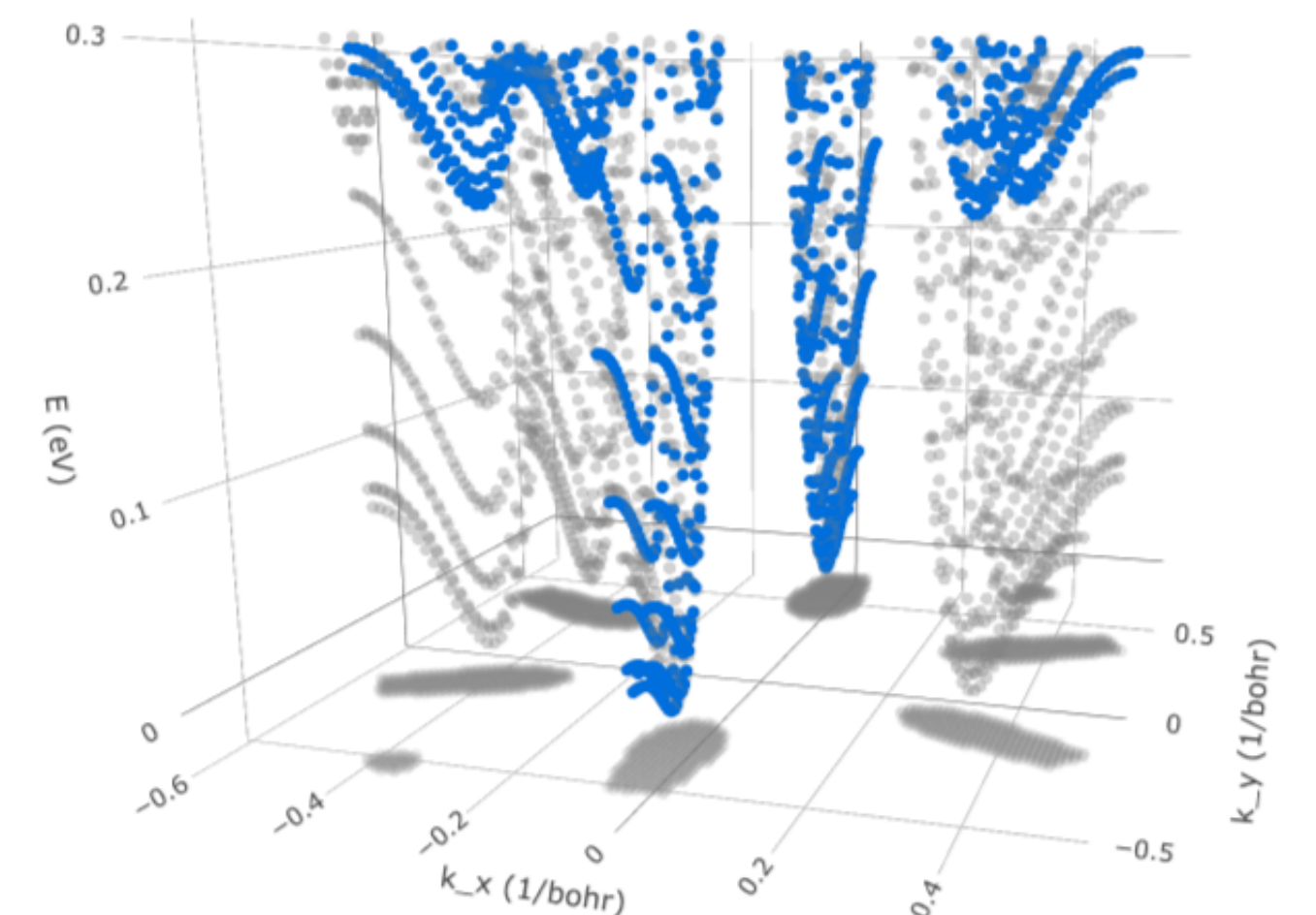
- Strain shifts the valleys out of reach, improving mobility by a factor 6.



Antimonene



Blue Phosphorene



- Works for group V buckled monolayers, and others...

# Perspectives for ML

- Descriptors:
  - Electronic structure features: number of valleys, Fermi velocity, DOS, etc...
  - Electron-phonon interactions: Intra- or intervalley, screenable or not, ...
- Databases:
  - Need more data!

The logo for EPFL (École Polytechnique Fédérale de Lausanne) in red.The logo for THEOS (Theory and Simulation of Materials) in red, with the text "THEOS" in a large font and "THEORY AND SIMULATION OF MATERIALS" in a smaller font below it.The logo for MARVEL (National Centre of Competence in Research) in black, with the text "MARVEL" in a large font and "NATIONAL CENTRE OF COMPETENCE IN RESEARCH" in a smaller font below it. The logo also features four red hexagons of varying shades.

@ EPFL:

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@ ULiège

- M. Verstraete